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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Attorney Docket: SLA0786

Inventor: Pooran Joshi, et al.

Confirmation No. 2314

Serial No.: 10/812,591

Group #: 2891

Filed: March 29, 2004

Examiner: Asok K. Sarkar

Title: HIGH DENSITY PLASMA PROCESS FOR THE FORMATION OF
SILICON DIOXIDE ON SILICON CARBIDE SUBSTRATESCommissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

ASSOCIATE POWER OF ATTORNEY

CHANGE OF CORRESPONDENCE ADDRESS

I hereby appoint Gerald Maliszewski, P. O. Box 270829 San Diego, CA 92198-29, U. S. Patent and Trademark Office Registration Number 38,054, as an associate attorney for the above-captioned matter, with full power of substitution and revocation, to prosecute this application and to transact all business in the Patent and Trademark Office connected therewith.

Please change the Correspondence address to that associated with Customer Number 55,286.

Date:

12/19/05

Respectfully submitted,

David C. Ripma, Registration # 27,672

David C. Ripma Patent Counsel
Sharp Laboratories of America, Inc.
5750 N.W. Pacific Rim Highway
Camas, WA 98607
Phone: (360) 834-8754
Facsimile: (360) 817-8505

Page 1 Associate Power of Attorney for Serial No. 10,812,591